



MATERIAIS NANOESTRUTURADOS E NANOTECNOLOGIAS

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Summary

- Introduction
- Fundamentals of Surface Energy
- •Chemical Potential as a Function of
 - **Surface Curvature**
 - •Further Reading

Introduction









• NANOSTRUTURES AND NANOMATERIALS POSSESS A LARGE FRACTION OF SURFACE AREA PER UNIT VOLUME.

• DUE TO THE **VAST SURFACE AREA** NANOSTRUTURES AND NANOMATERIALS POSSESS A **HUGE SURFACE ENERGY** .

• AND THUS, NANOSTRUTURES AND NANOMATERIALS ARE THERMODINAMICALLY UNSTABLE OR METASTABLE.



ONE OF THE GREAT CHALLENGES IN FABRICATION AND PROCESSING OF NANOMATERIALS IS TO OVERCOME THE SURFACE ENERGY, AND TO PREVENT THE NANOSTRUCTURES OR NANOMATERIALS FROM GROWTH IN SIZE, DRIVEN BY THE REDUCTION OF OVERALL SURFACE ENERGY.

Surface Energy



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•ATOMS OR MOLECULES ON A SOLID SURFACE POSSESS FEWER NEAREST NEIGHBORS OR CN, AND THUS HAVE UNSATISFIED BONDS EXPOSED TO THE SURFACE.

• BECAUSE OF THE DANGLING BONDS ON THE SURFACE, **SURFACE ATOMS** OR **MOLECULES** ARE **UNDER INWARDLY DIRECTED FORCE**.

• AND THUS, THE **BONF DISTANCE** BETWEEN THE SURFACE ATOMS OR **MOLECULES** AND **THE SUB-SURFACE ATOMS** OR **MOLECULES** IS **SMALLER** THAN THAT BETWEEN INTERIOR ATOMS OR MOLECULES.

Surface Energy



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WHEN SOLID PARTICLES ARE VERY SMALL, SUCH A DECREASE IN BOND LENGTH BETWEEN THE SURFACE ATOMS AND INTERIOR ATOMS BECOMES SIGNIFICANT AND THE LATTICE CONSTANTS OF THE ENTIRE SOLID PARTICLES SHOW AN APPRECIABLE REDUCTION.





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FOR A GIVEN SURFACE WITH A FIXED SURFACE AREA, THE SURFACE ENERGY CAN BE REDUCED THROUGH:

SURFACE RELAXATION, THE SURFACE ATOMS OR IONS SHIFT INWARDLY WHICH OCCUR MORE READILY IN LIQUID PHASE THAN IN SOLID SURFACE.

WHEN **SOLID PARTICLES** ARE **VERY SMALL**, SUCH A **DECREASE IN BOND LENGTH** BETWEEN THE SURFACE ATOMS AND INTERIOR ATOMS BECOMES SIGNIFICANT AND THE **LATTICE CONSTANTS** OF THE ENTIRE SOLID PARTICLES SHOW **AN APPRECIABLE REDUCTION**.



• THE EXTRA ENERGY POSSESSED BY THE SURFACE ATOMS IS DESCRIBED AS **SURFACE ENERGY**, OR **SURFACE TENSION**.

 \bullet SURFACE ENERGY, $\gamma\,$, is the energy required to create a unit area of New Surface:

$$\gamma = \left(\frac{\partial G}{\partial A}\right)_{n_{I},T,P}$$

γ- surface energy G – Gibbs energy A – surface area

Surface Energy

• ON A **NEW CREATED SURFACE**, EACH **ATOM** IS LOCATED IN **AN ASYMMETRIC ENVIRONMENT** AND WILL MOVE TOWARDS THE INTERIOR DUE TO BREAKING OF BONDS AT THE SURFACE.





• ON A NEW CREATED SURFACE, EACH ATOM IS LOCATED IN AN ASYMMETRIC ENVIRONMENT AND WILL MOVE TOWARDS THE INTERIOR DUE TO BREAKING OF BONDS AT THE SURFACE.

• AN EXTRA FORCE IS REQUIRED TO PULL THE SURFACE ATOMS BACK TO ITS ORIGINAL POSITION. FOR EACH ATOM, THIS SURFACE ENERGY IS:

$$\gamma = \frac{1}{2} N_b \varepsilon \rho_a$$

- γ surface energy
- N_b number of broken bonds
- $\epsilon-half$ of the bond strength
- ρ_a surface atomic density, i.e., the number of atoms of each area per area on the new surface

Surface Energy

The work W_{11} to bring two identical ideal surfaces in vacuum together is related to the surface energy γ_1 of the material:

 $W_{11} = -2 \gamma_1$ (normalized to unit area!)

 W_{11} corresponds to to the work of **cohesion** in an ideal case and is normalized to the area of the surfaces. This **work** should be identical to **separating** a body into two halves. In reality the separation process is irreversible (due to energy dissipation), thus the separation / cohesion work is larger than the surface energy.

 \Rightarrow high surface energy \leftrightarrow strong cohesion \rightarrow high boiling point...



about 1/6 new surface per structure element in the cleavage plane

substrate material	surface energy γ (mJ m ⁻²)		
mica	4500		
gold	~1000		
PTFE	19		
OTE (octadecane surface)	28		

⇒ high energy surfaces tend to reduce energy by adsorption of contaminants from environment !

Surface Tension

Surface tension γ is defined by the infinitesimal work dw required to increase the surface by an infinitesimal area $d\sigma$:

 $dw = \gamma \delta \sigma$



 \rightarrow work has to be applied to increase surface, since liquids tend to minimize their surface (spherical droplet) \rightarrow force balance

gas

 \rightarrow surface tension of liquids corresponds to surface energy of solids

 \rightarrow surface tension / surface energy correlates to evaporation enthalpy $\Delta H_{_{vap}}$ (approximation)

material	γ (mN m⁻¹)	∆ H_{vap} (kJ mo Γ¹)		
C ₆ H ₆	28.8	30.8	•	
MeOH	26.6	35.3		~ 5/6 new surface
H ₂ O	72.7	40.7		per structure
Hg	472	59.3		element



Cohesion

Cohesion forces act within a condensed material (liquid, solid) to keep it together.

work of cohesion W_{11} : free energy change, or reversible work done, to cleave / separate a material from contact to infinity in vacuum

W₁₁ = 2 A

– cohesion in amorphous solids and liquids is isotropic: \rightarrow random fracture plane (e.g. glass)

- cohesion in crystalline solids is anisotropic:

W₁₁

 \rightarrow fracture along crystal planes (e.g. Si single crystal wafer)



surface (free) energy

new cleaveage area





Adhesion

The adhesion forces act between the surfaces of two different condensed bodies in contact.



 \rightarrow this process can be split into two hypothetical steps:

a) generate new surface for materials 1 and 2 in vacuum: $W = \gamma_1 + \gamma_2$ (normalized to unit area!)

b) bring two new surfaces into contact (work of adhesion): W12

 \Rightarrow since all media attract each other (assuming neutral total charge) in vacuum: work of cohesion (W₁₁) and work of adhesion (W₁₂) are always positive (work is required to separate material)!



Surface Energy

• FOR A GIVEN **SURFACE** WITH A FIXED **SURFACE AREA**, THE **SURFACE ENERGY** CAN BE **REDUCED** THROUGH:

CHEMICAL AND PHYSICAL ADSORPTION ON SOLID SURFACES;





• FOR A GIVEN SURFACE WITH A FIXED SURFACE AREA, THE SURFACE ENERGY

Surface Energy

CAN BE **REDUCED** THROUGH:

COMPOSITION SEGREGATION OR **ENRICHMENT** OF IMPURITIES ON THE SURFACES;

IN NANOSTRUCTURES AND NANOMATERIALS PHASE SEGREGATION MAY PLAY A SIGNIFICANT ROLE IN THE REDUCTION OF SURFACE ENERGY, CONSIDERING THE GREAT IMPACT OF SURFACE ENERGY AND THE SHORT DIFFUSION DISTANCE.



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• AT THE INDIVIDUAL NANOSTRUCTURE LEVEL,

THE SURFACE ENERGY CAN BE REDUCED THROUGH:

REDUCE THE OVERALL SURFACE AREA, ASSUMING THE MATERIAL IS ENTIRELY ISOTROPIC

i) **COMBINING INDIVIDUAL NANOSTRUCTURES TOGETHER** TO FORM **LARGE STRUCTURES** SO AS TO REDUCE THE OVERALL SURFACE AREA;

SINTERING

OSTWALD RIPENING

ii) **AGGLOMERATION OF INDIVIDUAL NANOSTRUCTURES** WITHOUT ALTERING THE INDIVIDUAL NANOSTRUCTURES;





SINTERING

Output

Input

MM

C)

Sintering Time

Input

M

Output

Input

MM

100 µm





Output

 $\sim \sim \sim$

http://www.esrf.eu/UsersAndScience/Publications/Highlights/2002/Materials/MAT3





Six distinct mechanisms can contribute to the sintering of a consolidated mass of crystalline particles:(1) surface diffusion, (2) lattice diffusion from the surface, (3) vapor transport, (4) grain boundary diffusion, (5) lattice diffusion from the grain boundary, and (6) plastic flow. Only mechanisms 1 to 3 lead to densification, but all cause the necks to grow and so influence the rate of densification.

Introduction to Ceramics, W.D. Kingery, H.K. Bowen, D.R. Uhlmann, John Wiley & Sons, 1975, p. 475.







SINTERING

final

http://www.emi.fraunhofer.de/images/MAVO/Sinter2.gif

fracture

5 µm



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LET US CONSIDER TRANSFERING MATERIAL FROM AN INFINITE FLAT SURFACE TO A SPHERICAL SOLID PARTICLE.

AS A RESULT OF **TRANSFERRING** OF **dn ATOMS** FROM A **FLAT SOLID SURFACE** TO A **PARTICLE** WITH A **RADIUS** OF **R**, THE **VOLUME CHANGE** OF SPHERICAL PARTICLE, **dV**, IS EQUAL TO THE **ATOMIC VOLUME**, Ω , TIMES **dn**, THAT IS:

$$dV = 4\pi R^2 dR = \Omega dn$$



Fig. 2.10. Transport of n atoms from the flat surface of a semi-infinite reference solid to the curved surface of a solid sphere.

Nanostructures and Nanomaterials. Synthesis, Properties & Applications, G. Cao, ICP Imperial College Press, 2007 (ISBN 1-86094-480-9), p. 27.



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• CHEMICAL POTENTIAL AS A FUNCTION OF SURFACE CURVATURE

THE WORK PER ATOM TRANSFERED, $\Delta \mu$, EQUALS TO THE CHANGE OF CHEMICAL POTENTIAL, GIVEN BY:

$$\Delta \mu = \mu_c - \mu_{\infty} = \gamma \frac{dA}{dn} = \gamma 8\pi R dR \frac{\Omega}{dV}$$

 m_c – chemical potential of the particle surface

 $m_{\!\scriptscriptstyle \infty} - chemical \ potential \ of the flat \ surface$

 Ω - atomic volume



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Surface Energy as a Function of Surface Curvature

YOUNG-LAPLACE EQUATION

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THE YOUNG-LAPLACE EQUATION DESCRIBES THE CHEMICAL POTENTIAL OF AN ATOM IN A SPHERICAL SURFACE, WITH RESPECT TO A FLAT REFERENCE SURFACE.

$$\Delta \mu = 2\gamma \frac{\Omega}{R}$$

GENERALIZATION FOR ANY TYPE OF CURVED SURFACES:

$$\Delta \mu = \gamma \Omega \left(\frac{1}{R_1} + \frac{1}{R_2} \right)$$



Surface Energy as a Function of Surface Curvature

Convex curvature



Concave curvature

Fig. 2.11. Variation in solubility of silica with radius of curvature of surface. The positive radii of curvature are shown in cross-section as particles and projections from a planar surface; negative radii are shown as depressions or holes in the surface, and in the crevice between two particles. [R.K. Iler, *The Chemistry of Silica*, Wiley, New York, 1979.]

Nanostructures and Nanomaterials. Synthesis, Properties & Applications, G. Cao, ICP Imperial College Press, 2007 (ISBN 1-86094-480-9), p. 28.



FOR A **CONVEX SURFACE**, THE **CURVATURE** IS **POSITIVE**, AND THUS THE **CHEMICAL POTENTIAL** OF **AN ATOM** ON SUCH A SURFACE IS **HIGHER** THAN THAT ON A FLAT SURFACE. **MASS TRANSFER** FROM A **FLAT SURFACE** TO A **CONVEX SURFACE** RESULTS IN AN **INCREASE IN SURFACE CHEMICAL POTENTIAL**.

FOR A **CONCAVE SURFACE**, THE **CURVATURE** IS **NEGATIVE**, AND THUS THE **CHEMICAL POTENTIAL** OF **AN ATOM** ON SUCH A SURFACE IS **LOWER** THAN THAT ON A FLAT SURFACE. **MASS TRANSFER** FROM A **FLAT SURFACE** TO A **CONCAVE SURFACE** RESULTS IN AN **DECREASE IN SURFACE CHEMICAL POTENTIAL**.



• AT THE INDIVIDUAL NANOSTRUCTURE LEVEL,

THE SURFACE ENERGY CAN BE REDUCED THROUGH:

REDUCE THE OVERALL SURFACE AREA, ASSUMING THE MATERIAL IS ENTIRELY ISOTROPIC

 i) COMBINING INDIVIDUAL NANOSTRUCTURES
TOGETHER TO FORM LARGE STRUCTURES SO AS TO REDUCE THE OVERALL SURFACE AREA;



Surface Energy as a Function of Surface Curvature

TWO PARTICLES, WITH DIFFERENT RADII, R1 R2, INTO A SOLVENT

GIBBS-THOMPSON EQUATION

$$\ln\left(\frac{S_c}{S_{\infty}}\right) = \gamma \Omega \frac{R_1^{-1} + R_2^{-1}}{kT}$$

 S_c – solubility of a curved surface

 $S_{\scriptscriptstyle \infty}$ - solubility of a flat surface

NOTE THAT THE VAPOR PRESSURE OF SMALL PARTICLES IS NOTABLY HIGHER THAN THAT OF

THE BULK MATERIAL.

WHEN TWO PARTICLES WITH DIFFERENT RADII ARE PUT INTO A SOLVENT, EACH PARTICLE WILL DEVELOP AN EQUILIBRIUM WITH THE SURROUNDING SOLVENT.

THE SOLUBILITY OF THE SMALLER PARTICLE WILL BE LARGER THAN THAT OF THE LARGER

PARTICLE.



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OSTWALD RIPENING



Nanostructures and Nanomaterials. Synthesis, Properties & Applications, G. Cao, ICP Imperial College Press, 2007 (ISBN 1-86094-480-9), p. 27.



Michael Bowker Nature Materials 1, 205 - 206 (2002).



Surface Energy as a Function of Surface Curvature

OSTWALD RIPENING

THERE WOULD BE A NET DIFFUSION OF SOLUTE FROM PROXIMITY OF THE SMALL PARTICLE TO PROXIMITY OF THE LARGE PARTICLE.

TO MAINTAIN THE **EQUILIBRIUM**, SOLUTE WILL DEPOSIT ONTO THE SURFACE OF THE LARGE PARTICLE WHEREAS THE SMALL PARTICLE HAS TO CONTINUE DISSOLVING SO AS TO COMPENSATE FOR THE AMOUNT OF SOLUTE DIFFUSED AWAY.

THE SMALLER PARTICLE GETS SMALLER

THE LARGER PARTICLE GETS LARGER



• Nanostructures and Nanomaterials. Synthesis, Properties & Applications, G. Cao, ICP Imperial College Press, 2007 (ISBN 1-86094-480-9).

• Thin-Film Deposition. Principles & Practice, D. L. Smith McGraw-Hill, 1995 (ISBN 0-07-058502-4).